Attorney: D. Bruce Prout
Docket No.: 58059/N75
Inventor(s): Jean-Louis Stehle
Title: PROTECTED PATTERN MASK FOR
REFLECTION LITHOGRAPHY IN THE EXTREME
UV OR SOFT X-RAY RANGE
Sheet 1 of 2

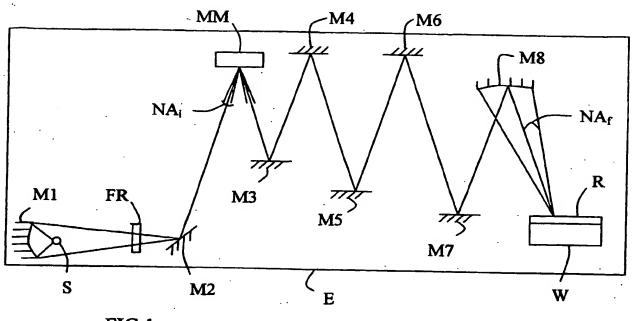
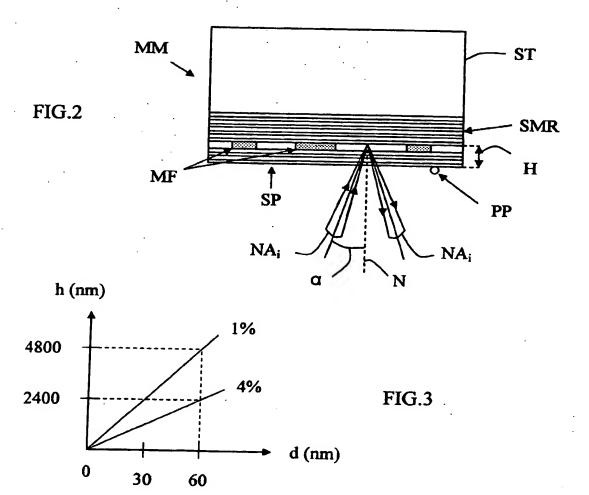


FIG.1



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